Notice of Allowability	Application No.	Applicant(s)
	10/709,926	TSAI ET AL.
	Examiner	Art Unit
	Jack Chen	2813
The MAILING DATE of this communication appeall claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this a or other appropriate communication (GHTS). This application is subject	pplication. If not included on will be mailed in due course. <b>THIS</b>
1. This communication is responsive to		
2. The allowed claim(s) is/are 1-11.		•
3. The drawings filed on <u>07 June 2004</u> are accepted by the E	xaminer.	
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority unall a)  All b)  Some* c)  None of the:</li> <li>1.  Certified copies of the priority documents have</li> <li>2.  Certified copies of the priority documents have</li> </ul>	been received.	<u>10/707,113</u> .
<ul> <li>3.  Copies of the certified copies of the priority doc</li> <li>International Bureau (PCT Rule 17.2(a)).</li> <li>* Certified copies not received:</li> </ul>	cuments have been received in thi	s national stage application from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	•	y complying with the requirements
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give		
<ul> <li>6.  CORRECTED DRAWINGS (as "replacement sheets") muse (a)  including changes required by the Notice of Draftspers</li> <li>1)  hereto or 2)  to Paper No./Mail Date</li> <li>(b)  including changes required by the attached Examiner's Paper No./Mail Date</li> </ul>	on's Patent Drawing Review (PT0	
Identifying indicia such as the application number (see 37 CFR 1, each sheet. Replacement sheet(s) should be labeled as such in the		
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT		
Attachment(s)		
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date</li> <li>Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ol>	6. Interview Summar Paper No./Mail D 7. Examiner's Amen	ate

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### **DETAILED ACTION**

In response to the communication filed on June 7, 2004, claims 1-11 are active in this application.

# **Priority**

1. Acknowledgment is made of applicant's claim for foreign priority under 35 U.S.C. 119(a)-(d). The certified copy has been filed in parent Application No. 10/707,113, filed on November 21, 2003.

#### Oath/Declaration

Oath/Declaration filed on June 7, 2004 has been considered.

### **EXAMINER'S AMENDMENT**

2. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

Re claim 11, page 2 of claim 11, line 16, change "region" to -layer--.

### Reasons For Allowance

3. Claims 1-11 are allowable over the prior art of record.

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4. The following is an examiner's statement of reasons for allowance: the prior art of record neither teach nor make obvious the claimed limitation of the instant application as a whole as recited in claim 1. In particular, the prior art does not teach or suggest the particular subset of the process steps for forming a deep trench capacitor by forming a material within the deep trench, covering the first conductive layer, and exposing a portion of the collar oxide layer, removing the exposed portion of the collar oxide layer for exposing the substrate at sidewalls of the top of the deep trench; removing the material layer; and forming a second conductive layer, covering the first conductive layer and the collar oxide layer, the second conductive layer contacting the substrate at the sidewalls of the top of the deep trench.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Bronner et al., U.S./6,110,792 and Wu et al., U.S./6,281,069 B1 teach the similar processes for forming the device.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jack Chen whose telephone number is (571)272-1689. The examiner can normally be reached on Monday-Friday (9:00am-6:30pm) alternate Monday off.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W Whitehead can be reached on (571)272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jack Chen

Primary Examiner Art Unit 2813